Standing Committee on the Law of Patents

Twenty-First Session
Geneva, November 3 to 7, 2014

REPORT ON THE INTERNATIONAL PATENT SYSTEM:
CERTAIN ASPECTS OF NATIONAL/REGIONAL PATENT LAWS

Document prepared by the Secretariat

1. The Standing Committee on the Law of Patents (SCP), at its twentieth session held from January 27 to 31, 2014, in Geneva, agreed that the information concerning certain aspects of national/regional patent laws, published on the SCP electronic forum website, would be updated based on input received.

2. Since the twentieth session of the SCP, information concerning certain aspects of patent laws has been received from Costa Rica, Georgia, Germany and Hong Kong China. Subsequently, the Secretariat updated SCP electronic forum website, which contains information concerning certain aspects of national/regional patent laws, namely, prior art, novelty, inventive step (obviousness), grace period, sufficiency of disclosure, exclusions from patentable subject matter and exceptions to the rights. It is available on the website of the SCP electronic forum at: http://www.wipo.int/scp/en/annex_ii.html.

3. If Member States so wish, under agenda item 5 entitled “Report on the International Patent System”, Member States may share information on recent development of national/regional patent laws with respect to the certain aspects mentioned above or various aspects of patent law in general.

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